

cutting positions formed over said fuse electrodes, wherein said insulating film has a thickness which allows said laser beam to pass through said insulating film and cut the fuse electrodes;

wherein said plurality of cutting positions are disposed in respective positions which are different from each other in a direction in which the fuse electrodes extend.

12. (New) An integrated circuit device comprising:

a plurality of fuse electrodes disposed in a parallel array with a pitch substantially equal to or less than a spot diameter of a laser beam to be used for cutting said fuse electrodes; and

an insulating film covering said plurality of fuse electrodes,

wherein said insulating film comprises:

a plurality of cutting positions formed over said fuse electrodes in which said insulating film has a thickness which allows said laser beam to pass through said insulating film and cut said fuse electrodes;

a plurality of regions of said insulating film having a thickness which prevents said laser beam from damaging said fuse electrodes, and

wherein said plurality of cutting positions are disposed in respective positions which are different from each other in a direction in which said fuse electrodes extend; and

wherein at least one of said plurality of fuse electrodes is disposed in a position in said insulating film that is different from a position of at least one other of said plurality of fuse electrodes, in a direction of a thickness of said insulating film.

13. (New) The integrated circuit device of claim 12, wherein each successive fuse electrode of said plurality of fuse electrodes is disposed alternately in a position in said insulating film that is different from a position of a preceding fuse electrode of said plurality of fuse electrodes, in a direction of a thickness of said insulating film.

14. (New) The integrated circuit device of claim 12, wherein at least one successive fuse electrode of said plurality of fuse electrodes is disposed in a position in said insulating film that is the same as a position of a preceding fuse electrode of said plurality of fuse electrodes, in a direction of a thickness of said insulating film.

---